## Abstract:

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There are disclosed a photosensitive resin composition which comprises

(A) a polyamic acid having recurring units represented by the formula (I):

$$\begin{array}{c|c} & COOH \\ \hline & OC - R^1 - CO - NH - R^2 - NH \\ \hline & COOH \\ \hline & wherein R^1 represents \\ \end{array}$$

represents a divalent organic group, and (B) an acryl compound having an amino group,

and also a photosensitive resin composition for an i-line stepper which further comprises a photoinitiator in addition to the photosensitive resin composition.